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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Kwang Su Choe, et al.

Docket: YOR920030293US1 (16818)

Serial No: ~~To be assigned~~
10/674,647

Date:

Filed: ~~Herewith~~ 9/30/2003

For: THIN BURIED OXIDES BY LOW-DOSE
OXYGEN IMPLANTATION INTO MODIFIED SILICON

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

**ASSOCIATE POWER OF ATTORNEY AND
REQUEST FOR CHANGE OF MAILING ADDRESS**

Sir:

Applicant(s), by (his/her/their) attorneys of record, hereby grant(s) an Associate Power of Attorney to:

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with full power of substitution to prosecute this application and transact all business in the United States Patent and Trademark Office in connection therewith.

Applicant(s) further request(s) that all future correspondence in connection with this application be directed and addressed to:

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